



**PATENT APPLICATION**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q62650

Toshiaki AOAI, et al.

**RECEIVED**

Appln. No.: 09/759,362

Group Art Unit: 1752

**MAR 03 2004**

Confirmation No.: 1920

Examiner: J. CHU

Filed: January 16, 2001

For: ELECTRON BEAM OR X-RAY NEGATIVE-WORKING RESIST COMPOSITION

**REQUEST FOR RECONSIDERATION UNDER 37 C.F.R. § 1.111**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This Amendment is submitted in response to the Office Action dated October 22, 2003.

A Petition for a one month extension of time is being concurrently filed, making a response due on or before February 23, 2004 (February 22, 2004 being a Sunday). Please enter and consider the remarks as submitted herewith on the accompanying pages.

**REMARKS**

Claims 1, 6-9 and 11-17 are all the claims pending in the application. Claims 9 and 11-17 are allowed. The Examiner has withdrawn the rejections based on Wakata et al and Wakata et al in view of Banks et al and has made a new rejection based on a newly cited reference, Imai et al.